

A NOVEL PURIFICATION PROCESS FOR USED SF₆ FROM ELECTRICAL EQUIPMENT

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AGENDA

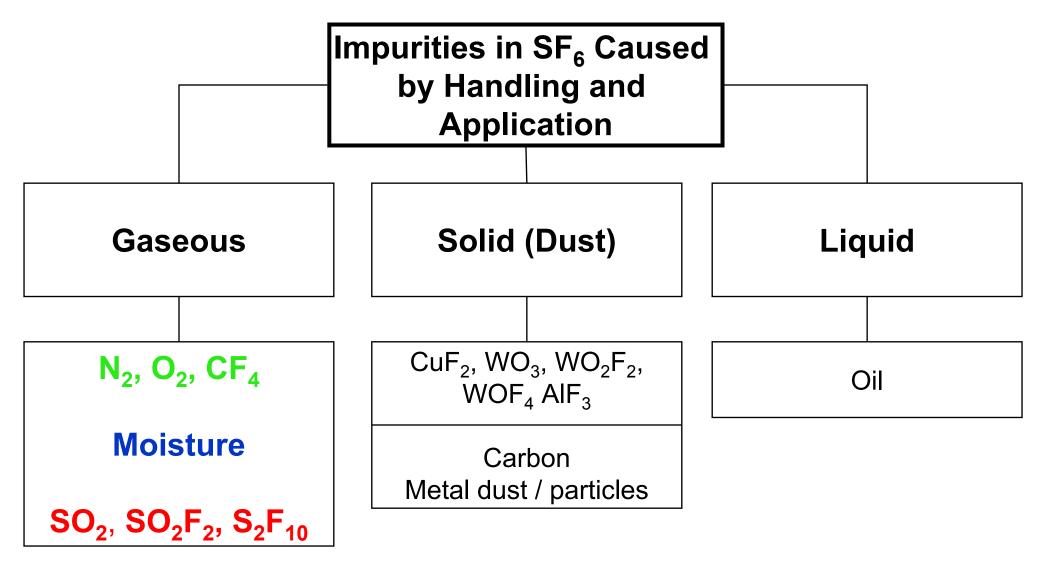
- Introduction
- SF₆ purification processes
- Test facility and pilot plant
- Conclusion







INTRODUCTION

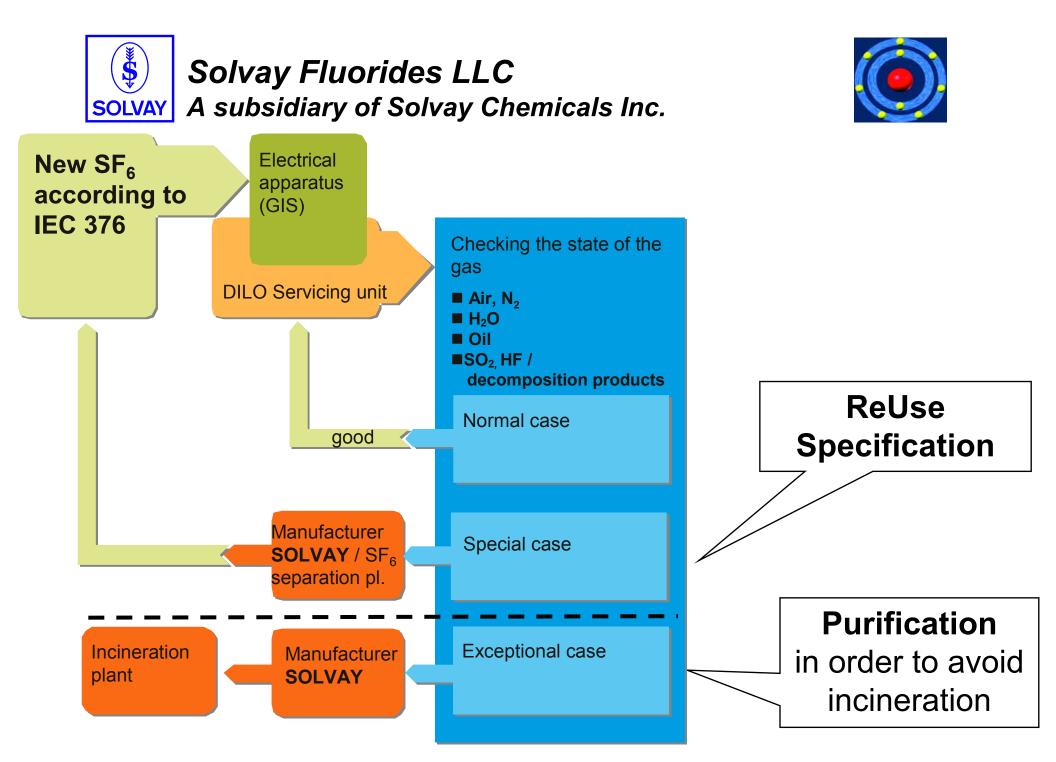






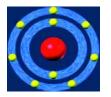
The SF₆ ReUse Program

- Analytical services, packaging, transport and reclaiming of used SF₆
- Re-introduction into the SF₆ production process.
 - separation of inert gases, but no purification!
- Output fulfills IEC 376 standard for virgin SF₆





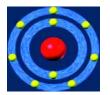




Average Impurities in Used SF₆ from Test Fields in 2001

Impurity (content)	IEC60480	Average value	Maximum value
(SF ₆)	96.99%	97.17%	99.99%
Air (O_2 , N_2)	3.0%	1.59%	59.74%
CF ₄		1.15%	2.70%
SO ₂	50ppm	300ppm	1.4%
SO ₂ F ₂		200ppm	1.5%
S ₂ F ₁₀	Not mentioned	174ppm	1.55%



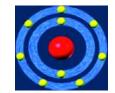


Threshold Limit Values for Possible SF₆ Decomposition Products

Contaminant	SF ₆	CF ₄	SO ₂ F ₂	SO ₂	HF	SOF ₂	SOF ₄	SF ₄	WF ₆	S ₂ F ₁₀
TLV (ppmv)	1000	1000	5	2	2	1.6	0.5	0.1	0.1	0.025

Note that S_2F_{10} could dominate the toxicity profile of any given sample

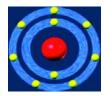




A subsidiary of Solvay Chemicals Inc. Impurities in Used SF₆, Behavior and Purification Processes

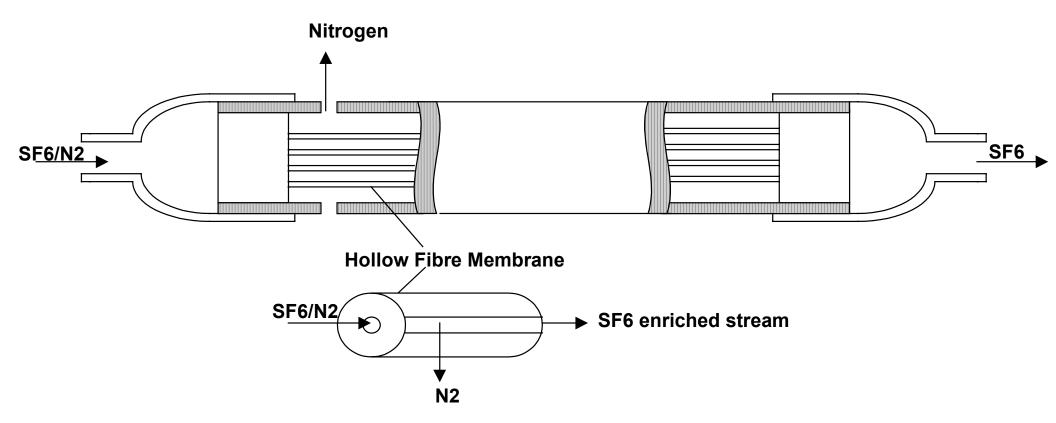
Impurity	Behavior / property	Purification process		
Air (O_2, N_2)	Inert	Membrane		
CF ₄	Inert	Adsorber		
SO ₂	Hydrolysable	Alkaline scrubber		
SO ₂ F ₂	Hydrolysable	Alkaline scrubber		
S ₂ F ₁₀	Stable / non hydrolysable	Pyrolysis / photolysis		



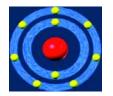


SF₆ PURIFICATION PROCESSES – Membrane

- separation of N_2 , O_2 from gaseous SF₆
- application for GIL

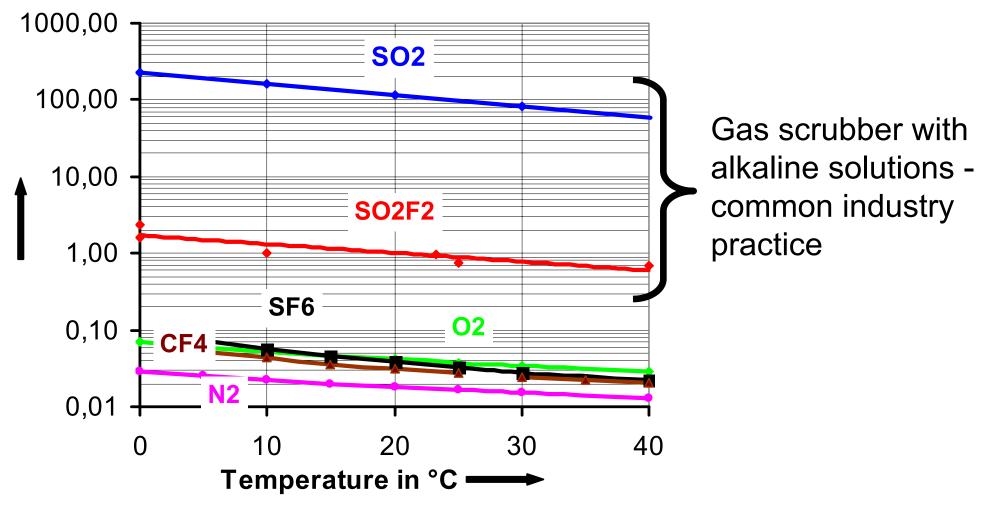




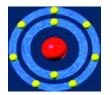


SF₆ PURIFICATION PROCESSES – Gas Scrubber

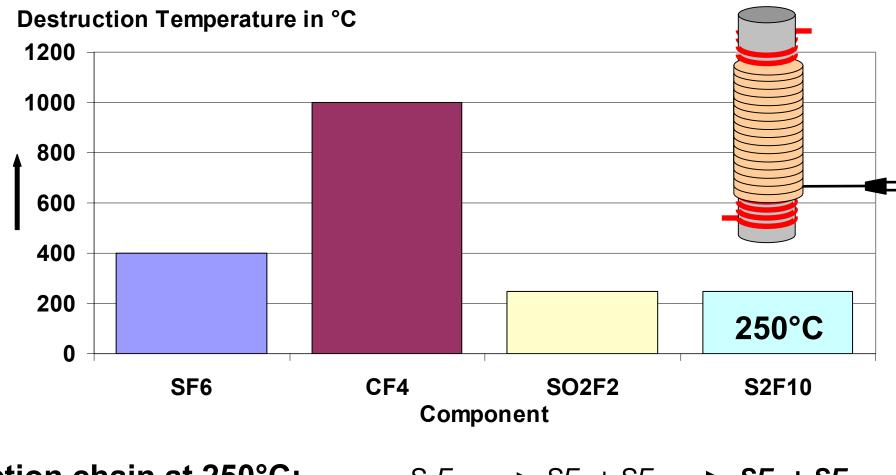
Solubility in g/kg H2O at 1.013bar







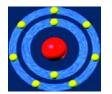
SF₆ PURIFICATION PROCESSES– Pyrolysis



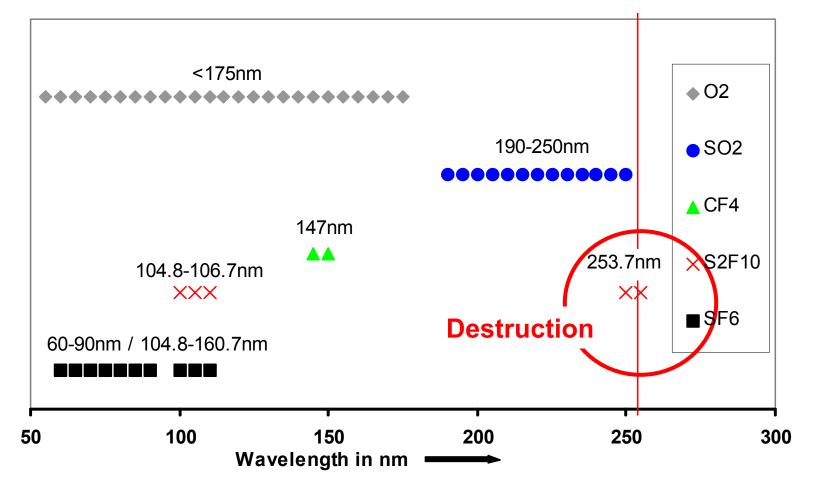
Reaction chain at 250°C:

 $S_2F_{10} \longrightarrow SF_5 + SF_5 \longrightarrow SF_4 + SF_6$ $SF_4 + H_2O \longrightarrow SOF_2 + 2HF$





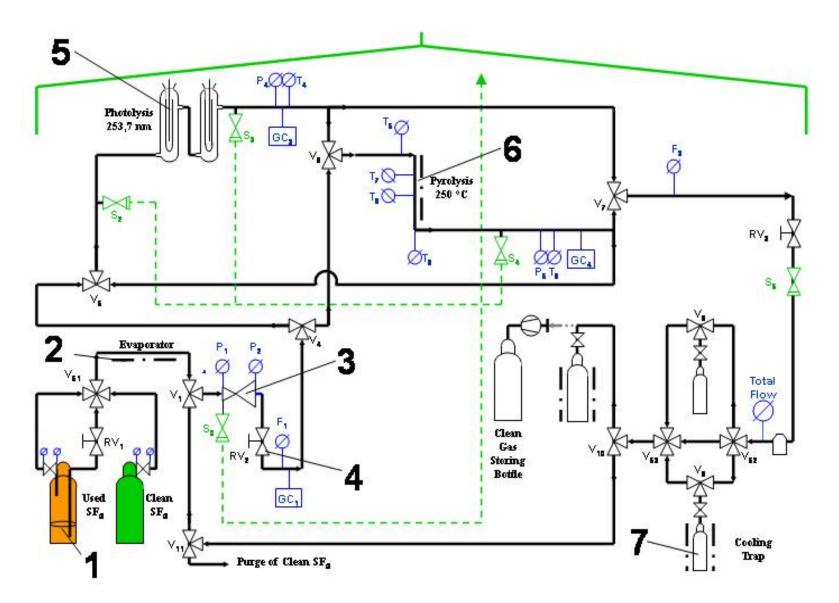
SF₆ PURIFICATION PROCESSES – Photolysis



Decomposition Products at 253.7nm: SOF_2 , SO_2F_2 , SO_2





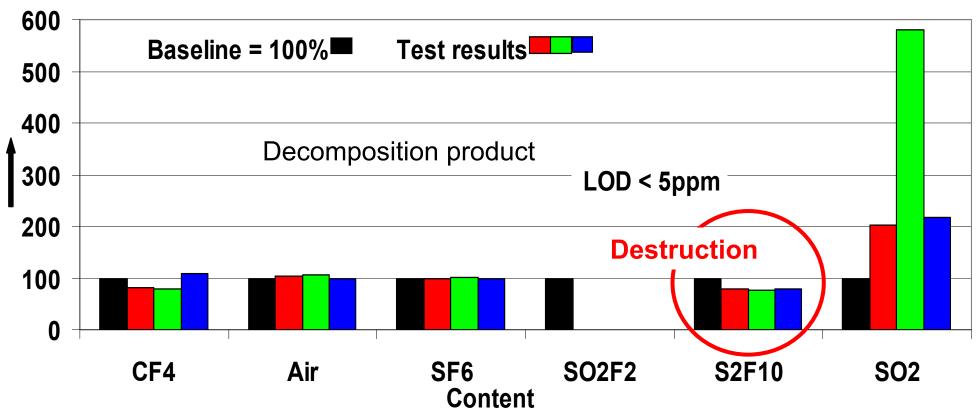






Pyrolysis Results

Deviation in % Related to Baseline



Conditions: Gas treatment time:

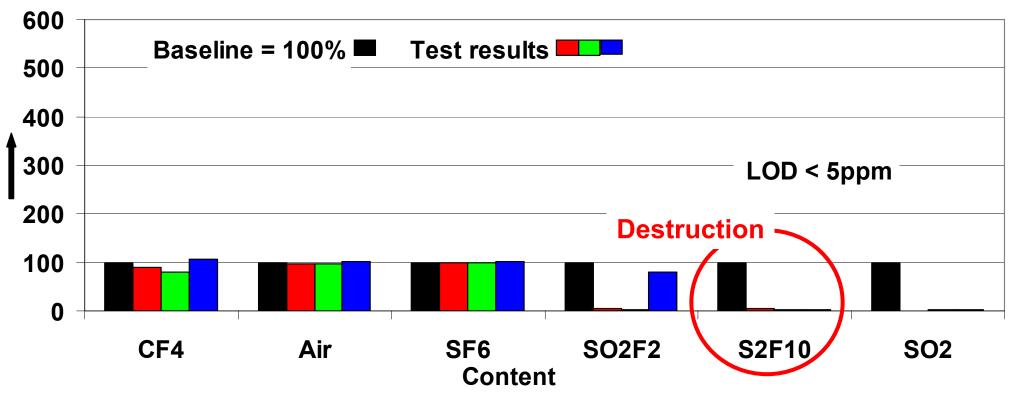
capacity 750W, Temperature = 250°C, Pressure = 0.8bar 7.6s at a volume flow of 0.5l/min





Photolysis Results

Deviation in % Related to Baseline



Conditions:

wavelength 253.7nm, capacity = 700W, Temperature = 90°C, Pressure = 0.8 bar

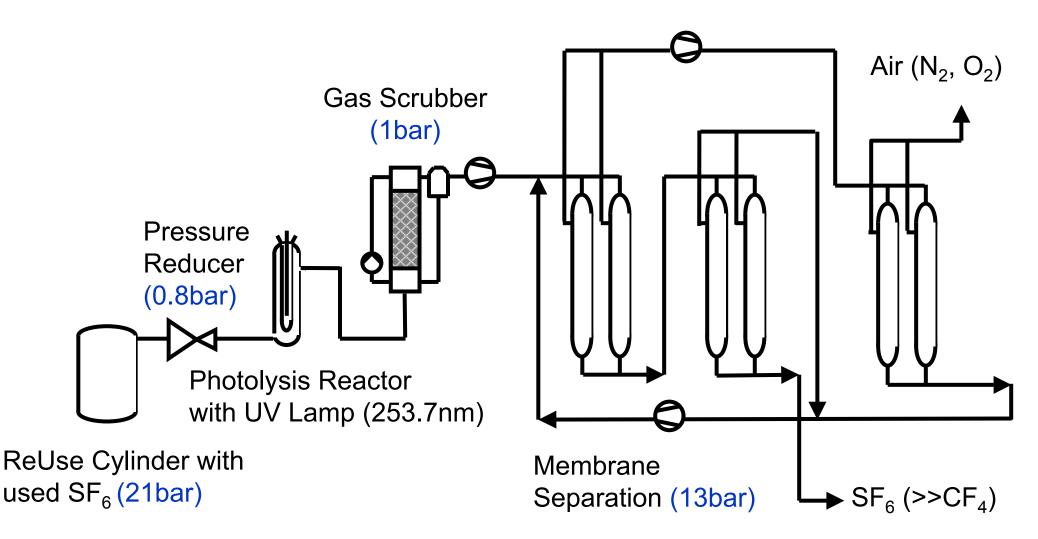
Gas treatment time: 1.26 min at a volume flow of 0.5l/min

SF6 Conference, Arizona, December 1-3, 2004



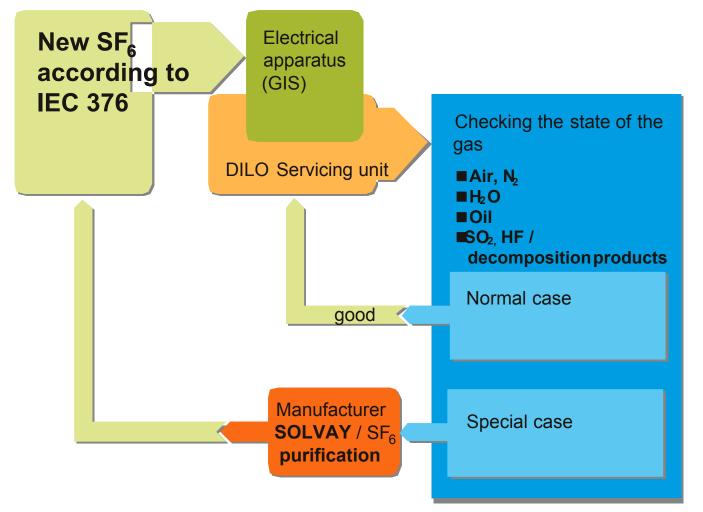


PILOT PLANT for the Pre-Treatment of Used SF₆









With purification capabilities, the closed loop handling concept is complete





CONCLUSION

- Photolysis is probably most appropriate for destruction of S_2F_{10} , further tests
- Pilot plant comprises of: photolysis reactor (S₂F₁₀) alkaline scrubber (SO₂, SO₂F₂) and membrane units (O₂, N₂)
- Completion of SF₆ ReUse Concept